

Title (en)
SUBSTRATE PROCESSING APPARATUS

Title (de)
SUBSTRATVERARBEITUNGSVORRICHTUNG

Title (fr)
APPAREIL DE TRAITEMENT DE SUBSTRAT

Publication
EP 3861570 A1 20210811 (EN)

Application
EP 19868791 A 20191004

Priority
• US 201862742000 P 20181005
• US 201916592431 A 20191003
• US 2019054780 W 20191004

Abstract (en)
[origin: WO2020072950A1] A substrate processing apparatus including a frame, a SCARA arm mounted to the frame at a shoulder joint having two links with at least one end effector dependent therefrom, the links defining an upper arm and a forearm, each end effector pivotally joined to the forearm at a wrist to rotate about a wrist axis, and a drive section with at least one degree of freedom operably coupled to the arm to rotate the arm about a shoulder axis articulating extension and retraction, wherein the end effector is coupled to a wrist joint pulley so that extension and retraction effects rotation of the pulley and end effector as a unit about the wrist axis, and wherein a height of the end effector is within a stack height profile of the wrist joint so that a total stack height is sized to conform with and pass through a pass-through of a slot valve.

IPC 8 full level
H01L 21/677 (2006.01); **B25J 9/06** (2006.01); **B25J 18/02** (2006.01); **B25J 18/04** (2006.01); **H01L 21/683** (2006.01)

CPC (source: EP KR US)
B25J 9/0021 (2013.01 - EP KR); **B25J 9/0087** (2013.01 - KR US); **B25J 9/043** (2013.01 - EP KR); **B25J 9/104** (2013.01 - EP KR);
B25J 11/0095 (2013.01 - EP KR); **B65G 47/907** (2013.01 - US); **H01L 21/67742** (2013.01 - EP KR); **H01L 21/68707** (2013.01 - KR US)

Designated contracting state (EPC)
AL AT BE BG CH CY CZ DE DK EE ES FI FR GB GR HR HU IE IS IT LI LT LU LV MC MK MT NL NO PL PT RO RS SE SI SK SM TR

Designated extension state (EPC)
BA ME

DOCDB simple family (publication)
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JP 2024020517 A 20240214; JP 7432588 B2 20240216; KR 102665380 B1 20240513; KR 20210068125 A 20210608;
KR 20240024282 A 20240223; US 11192239 B2 20211207; US 11691267 B2 20230704; US 2020122316 A1 20200423;
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